

UNITED STATES DEPARTMENT OF COMMERCE United Stat s Patent and Trademark Offic

Address: COMMISSIONER OF PATENTS AND TRADEMARKS

Washington, D.C. 20231

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR		A	TTORNEY DOCKET NO.
09/560,268	04/26/00	LEE		W	150.0056 010
_	IM52/0508 7)8 7	EXAMINER	
ATTN MARK	J GEBHARDT ASCH GEBHAR	,	DEO, D		
PO BOX 581		.DI I FI		ART UNIT	PAPER NUMBER
MINNEAPOLI	S MN 55458-1	415	·	1765	5
				DATE MAILED:	05/08/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trad marks

•			Annlinentia				
Office Action Summary		Application No.	Applicant(s)				
		09/560,268	LEE ET AL.				
	Office Action Summary	Examiner	Art Unit				
	·	DuyVu n Deo .	1765				
	The MAILING DATE of this communication appe	ears on the cover sheet with the co	orrespondence address				
THE N - Exten after: - If the - Failur - Apy fi	CRTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Issions of time may be available under the provisions of 37 CFR 1.11 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period re to reply within the set or extended period for reply will, by statute eply received by the Office later than three months after the mailing of patent term adjustment. See 37 CFR 1.704(b).	36 (a). In no event, however, may a reply be tily within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	mely filed /s will be considered timely. the mailing date of this communication. ED (35 U.S.C. § 133).				
1)🛛	Responsive to communication(s) filed on 301	<u> March 2001</u>					
2a)⊠	This action is FINAL . 2b) ☐ Th	is action is non-final.					
3)	The second secon						
Dispositi	on of Claims						
_	Claim(s) 37-39 and 46-63 is/are pending in th	e application.					
	4a) Of the above claim(s) is/are withdra						
5)🖂	Claim(s) <u>56-61</u> is/are allowed.						
6)🛛	Claim(s) <u>37-39,46-55,62, 63</u> is/are rejected.						
7)	The second secon						
8)□	Claims are subject to restriction and/o	r election requirement.					
Applicati	ion Papers	·					
9)	The specification is objected to by the Examin	er.					
10)	The drawing(s) filed on is/are objected		•				
11)	11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved.						
12)	The oath or declaration is objected to by the E	Examiner.					
	under 35 U.S.C. 🕻 119						
13)	Acknowledgment is made of a claim for foreig	n priority under 35 U.S.C. 💲 119	(a)-(d) or (f).				
	a) All b) Some * c) None of:						
	1. Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No						
*	Copies of the certified copies of the price application from the International Body See the attached detailed Office action for a lis	ureau (PCT Rule 17.2(a)).					
	Acknowledgement is made of a claim for dom						
Attachme	nt(s)	_					
16) 🗍 No	itice of References Cited (PTO-892) itice of Draftsperson's Patent Drawing Review (PTO-948) formation Disclosure Statement(s) (PTO-1449) Paper No(s	19) Notice of Inform	nary (PTO-413) Paper No(s) nal Patent Application (PTO-152)				

Application/Control Number: 09/560,268

Art Unit: 1765

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 37-39, 46-55, 62, 63 are rejected under 35 U.S.C. 103(a) as being unpatentable over Williams et al. and Hayashi et al. (US 5,482,895).

Williams describes an etching composition comprising a HCl (claimed mineral acid), hydrogen peroxide and deionized water (ab., col. 4, line 16-24; example 1). Unlike claims 38 and 39, Williams doesn't describe claimed ratio of acid:peroxide:water in a range of 1:1:35-1:1:5 or 1:1:25-1:1:10. His example uses 600 ml of deionized water, 150 ml of mineral acid, and 50 ml of peroxide, which corresponds to the ratio of 3:1:12. On the other hands, Hayashi teaches using a copper etchant having a ratio of mineral acid:peroxide of either 1:1 or 3:1 (col. 10, line 54-55). It would have been obvious for one skill in the art at the time of the invention that the optimum ratio of etchant's components is determined depending on the type of material being etched and through routine experimentation with an anticipation of an expected result. *In Re Aller et al.*, 105 USPQ 233.

Unlike claims 47, 51, 52, and 62, above prior art doesn't describe the composition has an etching rate for cobalt at 1000 angstrom/min and metal nitride at 50-250 angstrom/min. however, the etching rate of each metal and metal nitride would be obvious to one skill in the art to be determined through experimentation and test runs. Since composition of above prior art

Application/Control Number: 09/560,268

Art Unit: 1765

can be used to etch metal and metal alloys which would include cobalt and metal nitride. One skill in the art would find it obvious to do test runs in order to obtain the optimum processing parameters including etchant ratio for the etch rate of the metal or metal alloy being etched with an anticipation of an expected result. *In re Aller et al.*, 105 USPQ 233.

Allowable Subject Matter

3. Claims 56-61 are allowed because Williams doesn't describe the <u>composition consisting</u> essentially of a mineral acid, a peroxide, and deionized water.

Response to Arguments

4. Applicant's arguments filed 3/30/01 have been fully considered but they are not persuasive.

Referring to applicant's argument that there is no motivation to combine Williams and Hayashi. They both teach substantially the same composition for etching metal. Therefor, one skill in the art would find it obvious to view their teaching in order obtain a composition for etching metal and metal alloys.

Concerning to applicant's argument that Hayashi teaches a more concentration composition of HCl and hydrogen peroxide in col. 10, line 53-55. Examiner disagrees because col. 10, line 53-55 is more likely to display the ratio of the HCl and hydrogen peroxide than the actual concentration of HCl and hydrogen peroxide in the composition.

Referring to applicant's argument that Hayashi using one solution for cobalt and another for metal nitride is acknowledged. However, The composition of etching cobalt and metal nitride can be used to etch different material and each material would have different etch rate.

The composition of HCl and hydrogen peroxide is certainly can be used to etch metal and metal

Application/Control Number: 09/560,268

Art Unit: 1765

alloys as taught by Williams. As shown in the above rejection, depending on the material being etched, the ratio of HCl and hydrogen peroxide is determined through test runs in order to achieve an optimum etch for each metal or metal alloys.

Conclusion

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to DuyVu n Deo whose telephone number is 703-305-0515.

DVD

May 7, 2001

BENJAMIN L. UTECH SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700